

# Abstracts

## X-Band Noise Parameters of HEMT Devices at 300K and 12.5K

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*S. Weinreb and M. Pospieszalski. "X-Band Noise Parameters of HEMT Devices at 300K and 12.5K." 1985 MTT-S International Microwave Symposium Digest 85.1 (1985 [MWSYM]): 539-542.*

The four noise parameters of room-temperature and cryogenically-cooled HEMT's have been investigated. Two previously described structures, the quantum-well HEMT and the high-transconductance HEMT have been tested and compared with noise parameters of a MESFET (NE67383). It was demonstrated that the cryogenic noise performance of a HEMT is dependent on light illumination and may be or may not be better than that of a MESFET, depending on the device structure. The minimum noise temperature of  $T_{\text{sub min}} = 10.5 \pm 1.5\text{K}$  of the quantum-well HEMT, illuminated with light, measured at  $f = 8.4\text{ GHz}$  and  $T_{\text{sub a}} = 12.5\text{K}$  is the best yet published for field effect transistors.

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